- 1 9. (Three Times Amended) A method of removing at least one particle from a
- 2 [portion] <u>surface</u> of a metal [layer on] <u>plug disposed over</u> a substrate comprising:
- depositing a slurry onto a metal layer over the metal plug [the substrate];
- 4 polishing the metal layer [and the substrate]; and
- after polishing the metal layer, rinsing [a] the surface of the metal plug with a
- 6 solution comprising hydrogen peroxide.
- 1 18. (Three Times Amended) A method comprising:
- polishing [the] a metal layer over a conductive plug with a slurry; [and]
- after polishing the metal layer, introducing a rinsing solution onto [a] the [metal]
- 4 <u>conductive</u> plug, the rinsing solution [comprising] <u>comprises</u> hydrogen peroxide.